

Comparative Study of Density of Surface States in Solid and Hollow TiO₂ Microspheres

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Table S1. Film thicknesses of the four films based on the four kinds of TiO₂ microspheres.

Samples	SM	HM	rSM	rHM
Film thicknesses (μm)	13.5 (\pm 0.2)	13.2 (\pm 0.1)	13.7 (\pm 0.2)	13.4 (\pm 0.2)

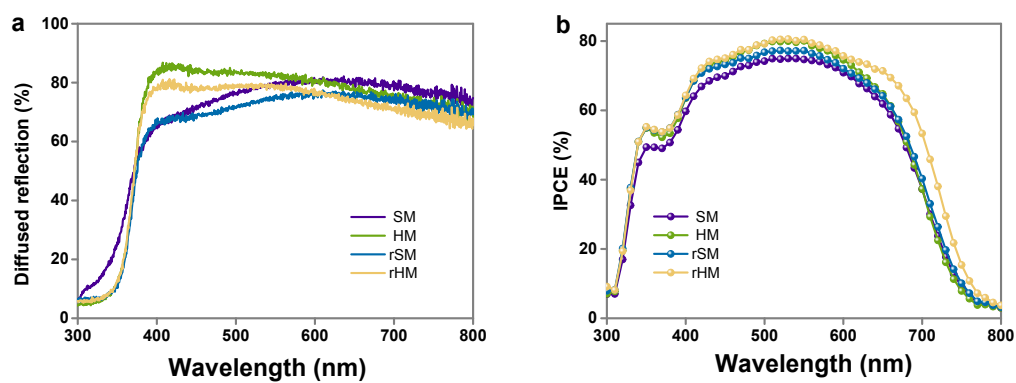


Fig. S1 (a) Diffused reflection spectra of the four photoanodes. (b) IPCE spectra of DSSCs fabricated from the four photoanodes.